

# EUROPEAN PATENT OFFICE

## Patent Abstracts of Japan

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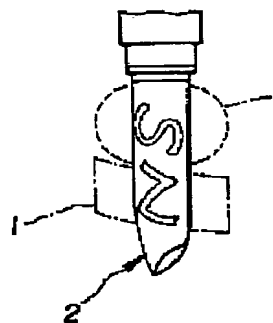
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TITLE : METHOD FOR FORMING PATTERN TO  
SOLID COSMETIC



ABSTRACT : PURPOSE: To obtain a method capable of preventing occurrence of volatile organic solvent mist of cosmetic base and forming a pattern onto a solid cosmetic in good workability.

CONSTITUTION: A pattern is drawn on a water-soluble film, etc., which is a medium other than a solid cosmetic such as lip stick and the water-soluble film, etc., on which pattern is drawn is bonded to lip stick and this water-soluble film is dissolved in water to transfer the pattern to the surface of the solid cosmetic.

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